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	Prepared by \$.M.G. Tracking Number Qd-1772 Date 423 04 Week Date
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b. Applicant(s)	g. Disclaimer I. Print Fig. q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix m. Searched Column r. Abstract
d. PCT	i. Title n. PTO-270/328 s. Sheets/Figs
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Docket No.: 8733.444.11-US

{Chemical Formula 2}

20. (Original) The method of claim 19, wherein components B and C are selected independently from groups shown in chemical formula 3, substituted-structure groups of the chemical formula 3 with a halogen, cyano, nitro, amino group, other substituted-structure groups

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ethenyl group, is selected from groups designated in chemical formula 2, substituted-structure groups of chemical formula 2 with a halogen, cyano, nitro, amino group, and other substituted-structure groups with a alkyl and haloalkyl, and cyanoalkyl group having 1 to 10 carbons or an aryl, alkyl, aryl, haloaryl, haloalkyl aryl, nitroaryl, cyanoaryl group having 3 to 8 carbons; {Chemical Formula 2}

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27. (Original) The method of claim 26, wherein components B and C are selected from groups shown in chemical formula 3, substituted-structure groups of chemical formula 3 with a halogen, cyano, nitro, amino group, other substituted-structure groups with carbonated groups of which carbon number n lies between 1 and 10 such as an alkyl, haloalkyl, and cyanoalkyl, and other carbonated groups of which carbon number lies between 3 and 8 such as an alkylaryl, haloalkyl aryl, nitroaryl, cyanoaryl;

{Chemical Formula 3}

$$(CH_2)_a$$
, $-0-$, $-C00-$, $-NHC0-$
 CH_3
 $-NHCO-$, $-CH_2CHCO-$

 $(CH_2O)_{\bar{n}}$, $(CH_2CH_2O)_{\bar{n}}$, $(CH_2)_{\bar{n}}O$

28. (Original) The method of claim 25, further comprising:

forming a gate line and a crossing data line on the first substrate;

forming a thin film transistor at a crossing between the gate and data lines; and forming a pixel electrode connected to the thin film transistor.